ABSTRACT

The invention provides a nontoxic, undangerous resist residue remover that enables removal of resist residues to be carried out without metal corrosion or other problems and with safety. The remover is an aqueous solution containing ammonium phosphate and/or condensed ammonium phosphate at a concentration of 20% by mass or less as expressed in terms of total phosphorous concentration and having a pH ranging from 1 to 10.